

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	619763	(develop or developer or developed or developing or development or developable) same (resist or photoresist or photopolymer or lithographic or plate or circuit or board or semiconductor)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/22 09:56
S2	128050	ammonium adj (fluoride or fluorine or chloride or chlorine or bromide or iodide)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/22 09:56
S3	9658	S1 and S2	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/22 09:56
S4	24521	((develop or developer or developed or developing or development or developable) same (resist or photoresist or photopolymer or lithographic or plate or circuit or board or semiconductor)).clm.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/22 09:57
S5	443	S2 and S4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/22 09:57